





RHODIUM

Sputtering Target

Rubidium is a chemical element with symbol Rb and atomic number 37. Rubidium is a soft, silvery-white metallic element of the alkali metal group, with an atomic mass of 85.4678. Elemental rubidium is highly reactive, with properties similar to those of other alkali metals, including rapid oxidation in air. High performance rhodium sputtering materials are used for thin film coating applications, CD-ROM, decoration, flat panel displays, functional coating as nicely as other optical information storage space industry, glass coating industry like car glass and architectural glass, optical communication, etc.

Features

- High purity
- Custom Sizes Available

Additional Characteristics

Stock No.	Purity	Diameter	Thickness
NS6130-10-1031	99.99%	50.8 mm ± 1mm	3 mm ± 0.5mm

Technical Specification

Molecular Formula	Molecular Weight	Thermal Conductivity
Rh	102.9 g/mol	150 W/m.K











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ISO 9001:2015 CERTIFIED COMPANY

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